| L Number | Hits | Search Text | DB | Time stamp |
|---|---|---|---|---|
| 1 | 1 | ("20020160546").PN. | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2002/11/25 13:07 |
| 2 | 14734 | photo adj resist | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2002/11/25 13:15 |
| 3 | 3895 | trench adj fill$2 | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2002/11/25 13:09 |
| 4 | 53493 | trench | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2002/11/25 13:09 |
| 5 | 22142 | cmp | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2002/11/25 13:10 |
| 6 | 23096 | planariz$3 | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2002/11/25 13:10 |
| 7 | 138 | (photo adj resist) and (trench adj fill$2) | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2002/11/25 13:10 |
| 8 | 61 | ((photo adj resist) and (trench adj fill$2)) and cmp | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2002/11/25 13:10 |
| 9 | 47 | (((photo adj resist) and (trench adj fill$2)) and cmp ) and  planariz$3 | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2002/11/25 13:10 |
| 10 | 266601 | resist | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2002/11/25 13:15 |
| 11 | 14734 | (photo adj resist) and resist | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2002/11/25 13:16 |
| 12 | 856 | (trench adj fill$2) and resist | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2002/11/25 13:16 |
| 13 | 351 | cmp  and ((trench adj fill$2) and resist) | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2002/11/25 13:16 |
| 14 | 254 | (cmp  and ((trench adj fill$2) and resist)) and  planariz$3 | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2002/11/25 13:17 |

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|---|---|---|---|---|
| 15 | 2 | ("5173439" \| "5719073").PN. | USPAT | 2002/11/25 13:39 |
| 16 | 1 | 6107187.URPN. | USPAT | 2002/11/25 13:39 |
| - | 1 | ("0000424").PN. | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2002/05/28 13:47 |
| - | 49798 | trench | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2002/05/28 13:47 |
| - | 389 | trench and shore | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2002/05/28 13:48 |
| - | 4 | (trench and shore) and (sti or (shallow adj trench adj isolation)) | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2002/05/28 14:29 |
| - | 1055 | (438/692).CCLS. | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2002/11/25 12:44 |
| - | 14 | ((438/692).CCLS.) and (shore or (shore adj D)) | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2002/05/28 14:35 |
| - | 3 | (((438/692).CCLS.) and (shore or (shore adj D))) and (sti or (shallow adj trench adj isolation)) | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2002/05/28 14:35 |
| - | 114633 | (silicon adj (substrate or wafer)) | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2002/05/28 15:34 |
| - | 127 | ((silicon adj (substrate or wafer))) and (shore or (shore adj d)) | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2002/05/28 15:49 |
| - | 4 | (((silicon adj (substrate or wafer))) and (shore or (shore adj d))) and trench | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2002/05/28 15:49 |